京都大学学術情報リポジトリ
KURENAI 紅
Kyoto University Research Information Repository

京都大学
KYOTO UNIVERSITY

Title	Investigation on origin of Z[1/2] center in SiC by deep level transient spectroscopy and electron paramagnetic resonance
Author(s)	Kawahara, Koutarou; Xuan Thang Trinh; Nguyen Tien Son; Janzen, Erik; Suda, Jun; Kimoto, Tsunenobu
Citation	Applied Physics Letters (2013), 102(11)
Issue Date	2013-03-19
URL	http://hdl.handle.net/2433/187953
Right	© 2013 American Institute of Physics. This article may be downloaded for personal use only. Any other use requires prior permission of the author and the American Institute of Physics.
Type	Journal Article
Textversion	publisher

Investigation on origin of Z 1 / 2 center in SiC by deep level transient spectroscopy and electron paramagnetic resonance

Koutarou Kawahara, Xuan Thang Trinh, Nguyen Tien Son, Erik Janzén, Jun Suda, and Tsunenobu Kimoto

Citation: Applied Physics Letters **102**, 112106 (2013); doi: 10.1063/1.4796141
View online: http://dx.doi.org/10.1063/1.4796141
View Table of Contents: http://scitation.aip.org/content/aip/journal/apl/102/11?ver=pdfcov
Published by the AIP Publishing

Articles you may be interested in
Resolving the E H 6 / 7 level in 4H-SiC by Laplace-transform deep level transient spectroscopy
Appl. Phys. Lett. **102**, 152108 (2013); 10.1063/1.4802248

Deep level defects in Si-doped Al x Ga 1 x N films grown by molecular-beam epitaxy
Appl. Phys. Lett. **86**, 152109 (2005); 10.1063/1.1887817

Anomalous behaviors of E 1 E 2 deep level defects in 6H silicon carbide
Appl. Phys. Lett. **86**, 031903 (2005); 10.1063/1.1853523

Formation of the Z 1,2 deep-level defects in 4H-SiC epitaxial layers: Evidence for nitrogen participation
Appl. Phys. Lett. **81**, 4841 (2002); 10.1063/1.1529314

Annealing behavior of vacancies and Z 1/2 levels in electron-irradiated 4H–SiC studied by positron annihilation and deep-level transient spectroscopy
Appl. Phys. Lett. **79**, 3950 (2001); 10.1063/1.1426259

This article is copyrighted as indicated in the article. Reuse of AIP content is subject to the terms at: http://scitation.aip.org/termsconditions. Downloaded to IP: 130.54.110.72 On: Thu, 05 Jun 2014 04:13:16

APPLIED PHYSICS LETTERS **102**, 112106 (2013)

Investigation on origin of $Z_{1/2}$ center in SiC by deep level transient spectroscopy and electron paramagnetic resonance

Koutarou Kawahara,[1,a)] Xuan Thang Trinh,[2] Nguyen Tien Son,[2] Erik Janzén,[2] Jun Suda,[1] and Tsunenobu Kimoto[1,b)]
[1]*Department of Electronic Science and Engineering, Kyoto University, Katsura, Nishikyo, Kyoto 615-8510, Japan*
[2]*Department of Physics Chemistry and Biology, Linköping University, 581 83 Linköping, Sweden*

(Received 26 December 2012; accepted 8 March 2013; published online 19 March 2013)

The $Z_{1/2}$ center in n-type 4H-SiC epilayers—a dominant deep level limiting the carrier lifetime—has been investigated. Using capacitance versus voltage (*C-V*) measurements and deep level transient spectroscopy (DLTS), we show that the $Z_{1/2}$ center is responsible for the carrier compensation in n-type 4H-SiC epilayers irradiated by low-energy (250 keV) electrons. The concentration of the $Z_{1/2}$ defect obtained by *C-V* and DLTS correlates well with that of the carbon vacancy (V_C) determined by electron paramagnetic resonance, suggesting that the $Z_{1/2}$ deep level originates from V_C. © *2013 American Institute of Physics*. [http://dx.doi.org/10.1063/1.4796141]

SiC is an attractive semiconductor for realizing high-power, high-temperature, and high-frequency devices. Deep levels in semiconductors can act either as carrier traps reducing the conductivity or recombination centers limiting the carrier lifetimes. The $Z_{1/2}$ center[1–3] is one of the most important deep levels in 4H-SiC, known as a lifetime killer.[4,5] The origin of the $Z_{1/2}$ center seems to include a carbon vacancy (V_C) because (i) this defect is generated by irradiation with electrons of energy as low as 100 keV,[6–8] which corresponds to the threshold energy that can displace only carbon atoms in SiC and (ii) a lower $Z_{1/2}$ concentration is observed in SiC epilayers grown under C-rich condition.[9]

Based on the correlation between the energy determined by deep level transient spectroscopy (DLTS) for the $Z_{1/2}$ center and by electron paramagnetic resonance (EPR) for the single negative C vacancy ($V_C(-)$),[10] the $Z_{1/2}$ center has recently been suggested to be the acceptor level of V_C.[11] In this paper, we will show the correlation in concentration between the $Z_{1/2}$ defect (obtained by capacitance-voltage (*C-V*) and DLTS) and V_C (determined by EPR) in n-type 4H-SiC irradiated by low-energy (250 keV) electrons with various electron fluences.

A direct comparison of the defect concentration determined by DLTS (or *C-V*) and by EPR is not easy. EPR measurements are suitable for relatively high defect concentrations (>10^{12} spins), which require high electron fluences to create. However, materials irradiated with high electron fluences often become highly resistive and are not suitable for DLTS and *C-V* measurements. Therefore, in previous studies, samples used for DLTS were irradiated with much lower electron fluences compared to samples used for EPR measurements.[12] In this study, in order to be able to characterize the same samples in *C-V*, DLTS, and EPR experiments, we chose n-type thick 4H-SiC epilayers with a relatively high N concentration ($N_d \sim 1.6 \times 10^{17}$ cm^{-3}) so that the materials can still be used for electrical measurements after irradiation with high electron fluences.

The starting materials are n-type 4H-SiC epilayers (thickness: 100 μm, N_d : 1.6×10^{17} cm^{-3}). The epilayers were irradiated by 250 keV electrons with different fluences: (A) 7.5×10^{18} cm^{-2}, (B) 7.2×10^{18} cm^{-2}, (C) 5.7×10^{18} cm^{-2}, (D) 4.3×10^{18} cm^{-2}, and (E) 3.1×10^{18} cm^{-2}. Ni/SiC Schottky structures have been made on the samples used for *C-V*, *I-V*, and DLTS measurements while the substrate of the other set of samples to be used for EPR was removed by mechanical polishing. For data sampling in all DLTS measurements, a period width of 0.205 s and a frequency of 1 MHz were employed. In DLTS measurements, the reverse bias voltage was varied in the range of 0–100 V, which corresponds to the monitored depth of about 100–800 nm in samples A–E. EPR measurements were performed on an X-band (~9.4 GHz) Bruker E500 spectrometer equipped with a continuous He-flow cryostat, allowing the sample temperature regulation in the range of 4–295 K. In photoexcitation EPR (photo-EPR) experiments, a 200 W halogen lamp and appropriate optical filters were used for excitation.

Figure 1(a) shows the *C-V* characteristics at room temperature (RT) obtained from SiC irradiated with different fluences. The capacitance of samples A–D is very small and almost constant independent of the bias voltage, indicating that these samples have a completely compensated region (CR) caused by electron capture of deep levels (these samples have a very thick depletion region even under 0 V bias). Figure 1(b) shows the dependence of the CR thickness (d_{CR}) on the electron fluence, which was derived from the equation: $d_{CR} = \epsilon/C$, where ϵ the dielectric constant and C the capacitance per unit area obtained from Fig. 1(a). Samples irradiated with a higher fluence show a thicker CR, indicating that deep levels are not uniformly distributed along the depth. Figure 2 shows depth profiles of the $Z_{1/2}$ center in lower doping 4H-SiC epilayers ($N_d \sim 1.6 \times 10^{15}$ cm^{-3}; initial $Z_{1/2}$ concentration: 1.7×10^{13} cm^{-3}) after 250 keV electron irradiation with various fluences (3×10^{15} cm^{-2}, 1×10^{16} cm^{-2}, and 2×10^{16} cm^{-2}). Because the CR region is formed where the trap concentration exceeds the doping

a)Electronic mail: kawahara@semicon.kuee.kyoto-u.ac.jp.
b)Also at Photonics and Electronics Science and Engineering Center (PESEC), Kyoto University, Katsura Campus, Nishikyo-ku, Kyoto 615-8510, Japan.

 © 2013 American Institute of Physics

This article is copyrighted as indicated in the article. Reuse of AIP content is subject to the terms at: http://scitation.aip.org/termsconditions. Downloaded to IP: 130.54.110.72 On: Thu, 05 Jun 2014 04:13:16

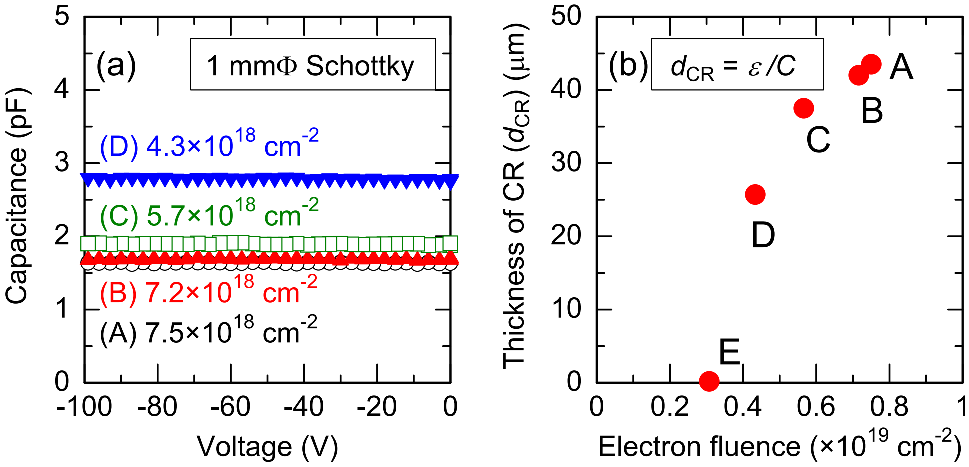

FIG. 1. (a) *C-V* characteristics at RT of samples irradiated by low-energy (250 keV) electrons with various fluences (circles: 7.5×10^{18} cm^{-2}, triangles: 7.2×10^{18} cm^{-2}, squares: 5.7×10^{18} cm^{-2}, reverse triangles: 4.3×10^{18} cm^{-2}). (b) Thickness of the compensated region (d_{CR}) in samples A–E calculated from the constant capacitance shown in Fig. 1(a).

concentration, a higher electron fluence should lead to a thicker d_{CR} as shown in Fig. 1(b).

Figure 3 shows DLTS spectra observed in samples A and E. The spectrum in the lower temperature region of sample A was obtained by current deep level transient spectroscopy (I-DLTS) because the very low capacitance (caused by severe compensation) disturbed capacitance deep level transient spectroscopy (C-DLTS) measurements. At higher temperatures (>400 K), the capacitance recovered to the value before electron irradiation, which enabled C-DLTS measurements of irradiated samples. As shown in Fig. 3, ET1 ($E_C - 0.30$ eV),[7] EH$_1$ ($E_C - 0.34$ eV),[13] Z$_{1/2}$ ($E_C - 0.67$ eV),[1] EH$_3$ ($E_C - 0.72$ eV),[13] EH$_5$ ($E_C - 1.2$ eV),[13] ET4 ($E_C - 1.3$ eV), and EH$_{6/7}$ ($E_C - 1.5$ eV)[13] centers were observed in the irradiated samples. The activation energy was derived with assuming a temperature independent capture cross section (σ). Taking into account that the activation energy for σ of Z$_{1/2}$ center (which corresponds to the barrier for capturing the second electron to the Z$_{1/2}$ level) is 0.074 eV,[14,15] the energy level of Z$_{1/2}$ center is recalculated to be at $\sim E_C - 0.59$ eV. All these deep levels are often observed in irradiated 4H-SiC except for the ET4 center, which is not easy to be separated from the EH$_{6/7}$ center because of severe overlapping. Among these centers, the Z$_{1/2}$ center has the highest

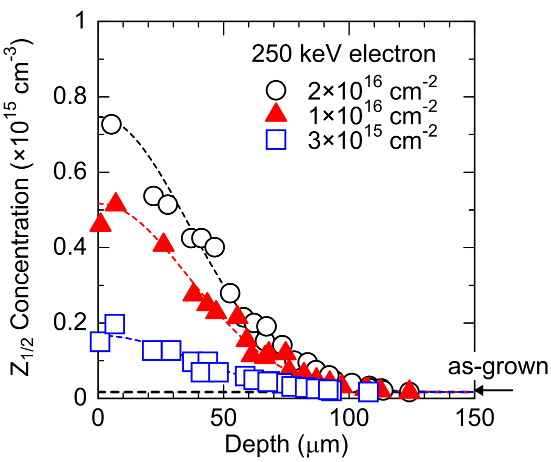

FIG. 2. Depth profiles of the Z$_{1/2}$ center in low-doped 4H-SiC epilayers (N_d : 1.6×10^{15} cm^{-3}, initial Z$_{1/2}$ concentration: 1.7×10^{13} cm^{-3}) after 250-keV-electron irradiation with various fluences (circles: 2×10^{16} cm^{-2}, triangles: 1×10^{16} cm^{-2}, squares: 3×10^{15} cm^{-2}).

concentration although the absolute concentration could not be evaluated due to very high trap concentrations (the Z$_{1/2}$ concentration in sample E is about 1×10^{17} cm^{-3} while N_d is 1.6×10^{17} cm^{-3}).

Figure 4 shows the carrier concentration (filled circles) and the Fermi level (circles) in the CR of samples A–E. The carrier concentration n in the CR was roughly estimated from the resistivity ρ in the CR of each sample using the equation: $n = 1/e\rho\mu$. The ρ value was calculated from the series resistance of Schottky barrier diodes (R) obtained from *I-V* measurements using the equation: $\rho = R/d_{CR}$. The electron mobility μ in the CR was assumed to be 370 cm^2/Vs using empirical equations given in a paper.[16] For this estimation of μ, an ionized impurity concentration of 3.2×10^{17} cm^{-3} was used because there should be ionized donors of 1.6×10^{17} cm^{-3} and traps filled with electrons of 1.6×10^{17} cm^{-3}. The Fermi level E_F in the CR can be estimated from the carrier concentration n using the equation: $E_F = E_C - kT\ln(N_C/n)$, and E_F is evaluated to be approximately at $E_C - 0.53$ eV in samples A–D, which is close to the energy level of the Z$_{1/2}$ center as shown in Fig. 4. With the Fermi level located at $E_C - 0.53$ eV, the Z$_{1/2}$ center ($E_C - 0.59$ eV) is occupied with electrons (the occupancy ~91% at 300 K). Taking into account that Z$_{1/2}$ has the highest concentration (over 1×10^{17} cm^{-3}) among deep levels observed in these samples, this defect should be the dominant compensating center, creating the CR.

It has been shown that in darkness most of V$_C$ are in the double negative charge state, giving rise to no EPR signal.[11] The observation of the EPR signal of V$_C$(−) requires illumination. In all samples, the EPR signal of V$_C$(−) is found to be dominant, suggesting that the acceptor levels of V$_C$ play a key role in the formation of the CR in studied samples. Figure 5 shows the dependence of the area density of V$_C$(−) in the samples A–E obtained by EPR measurements under illumination with light of photon energy smaller than 1.6 eV, and the value $0.1N_d d_{CR}$ on the electron fluence. It should be noted here that under illumination, V$_C$ can be in the neutral, single-negative, or double-negative charge state.[11] The V$_C$(−) volume density should be limited by N_d because an electron is needed for V$_C$ to become V$_C$(−). The value $N_d d_{CR}$ corresponds to the maximum value of the V$_C$(−) area density under an assumption that almost all V$_C$(−) signal comes from the CR. The assumption is reasonable because

This article is copyrighted as indicated in the article. Reuse of AIP content is subject to the terms at: http://scitation.aip.org/termsconditions. Downloaded to IP: 130.54.110.72 On: Thu, 05 Jun 2014 04:13:16

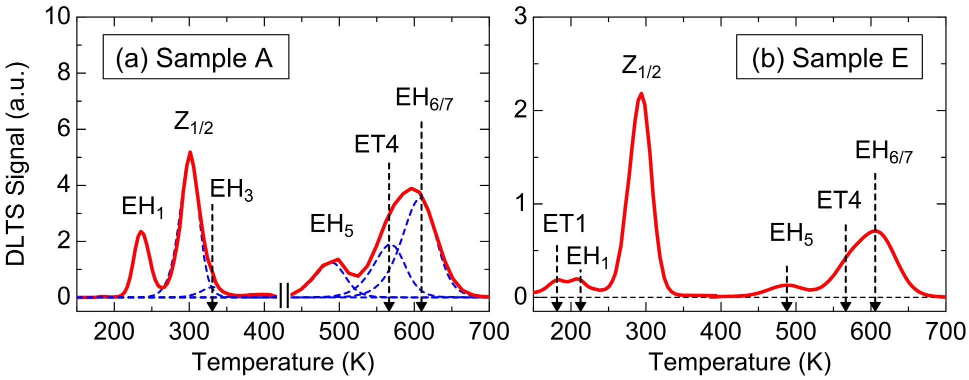

FIG. 3. DLTS spectra observed in samples (a) A (electron fluence: 7.5×10^{18} cm^{-2}) and (b) E (electron fluence: 3.1×10^{18} cm^{-2}). The lower temperature region of the spectrum in sample A was obtained by I-DLTS.

the V_C density in the CR is much higher than that in the tail uncompensated region, and most of V_C in the tail region should be in the double-negative (2−) charge state since the concentration of V_C is lower than that of donor concentration and the Fermi level is near the N shallow donor. As shown in Fig. 5, 10% of $N_d d_{CR}$ shows a good agreement with the $V_C(-)$ area density obtained by EPR measurements, indicating that under illumination at 100 K, about 10% of electrons in the CR exists as $V_C(-)$, while most of the other electrons may do as $V_C(2-)$. Note that the calculated value $0.1 N_d d_{CR}$ in the sample E is considerably smaller than the $V_C(-)$ area density obtained by EPR. Although the assumption that the EPR signal of $V_C(-)$ comes mainly from the CR is reasonable for samples A–D with thick CR, it is not valid for sample E, which has a very thin CR and the amount of V_C in the uncompensated region cannot be neglected compared to that in the very thin CR (~0.17 μm). Neglecting the contribution of V_C in the uncompensated region leads to the underestimation of the value $N_d d_{CR}$ in sample E. These EPR results with V_C having the highest density among all defects in the samples A–E and the $V_C(-)$ density following the maximum value of $V_C(-)$ density limited by N_d indicate that V_C is the dominant defect creating the CR.

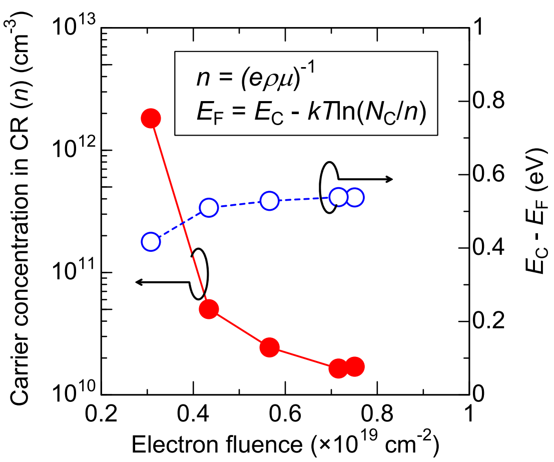

FIG. 4. The dependence on the electron fluence of the carrier concentration n and the Fermi level at 300 K in the CR in samples A–E. Here, n was estimated from the resistivity ρ in the CR for each sample.

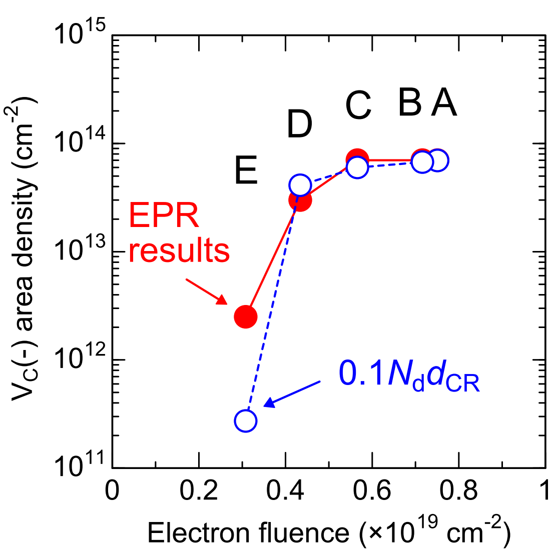

FIG. 5. Electron fluence dependence of the area density of carbon vacancy in the single-negative charge state ($V_C(-)$) in samples A–E obtained by EPR measurements under illumination with light of photon energy smaller than 1.6 eV, and the $0.1 N_d d_{CR}$ value. $N_d d_{CR}$ corresponds to the maximum $V_C(-)$ area density.

Comparing the data obtained from DLTS, *C-V*, and EPR measurements, it is clear that (i) the dominant deep level in samples A–E is the $Z_{1/2}$ center and the dominant point defect is V_C and (ii) the compensation in irradiated samples is caused by electron capture to the $Z_{1/2}$ center (as shown from DLTS) and to the acceptor levels of V_C (as shown in EPR). Thus, the $Z_{1/2}$ center, which capture two electrons as known from DLTS,[14] should be related to the double negative charge state of V_C (it is known that the EH_7 DLTS level and

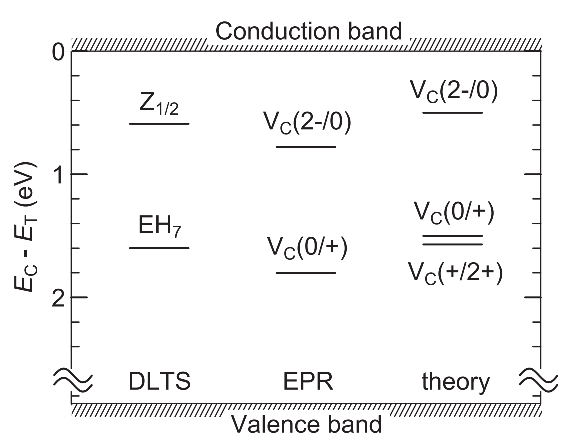

FIG. 6. Overview of the activation energy of deep levels obtained by DLTS (in this paper) and the energy of the (2−/0) and (0/+) levels of V_C determined by photo-EPR (Ref. 11) with respect to the conduction band minimum. The optical transitions determined by EPR involve a possible Franck-Condon shift, which has to be taken into account to be compared with the activation energy determined by DLTS. The energy levels of V_C in different charge states obtained by *ab initio* calculation (Ref. 18) are also shown for comparison.

This article is copyrighted as indicated in the article. Reuse of AIP content is subject to the terms at: http://scitation.aip.org/termsconditions. Downloaded to IP: 130.54.110.72 On: Thu, 05 Jun 2014 04:13:16

the $Z_{1/2}$ center originate from the same defect,[7,17] and EH_7 is related to the (0/+) charge state of V_C (Ref. 11)).

Figure 6 shows the activation energy (E_{act}) of deep levels obtained by DLTS and the optical transition levels related to V_C levels (E_{exc}) determined by photo-EPR[11] with respect to the conduction band edge ($E_C = 0$). To compare E_{exc} with E_{act}, a possible Franck-Condon shift involved in the optical transitions has to be taken into account ($E_{act} = E_{exc} - E_{FC}$). The activation energy of V_C obtained by *ab initio* calculations[18] are also shown in Fig. 6, which agrees well with the energy levels obtained by DLTS and EPR measurements.

In summary, using n-type 4H-SiC epitaxial layers irradiated by low-energy (250 keV) electrons, which can mainly create defects in the C sub-lattice (V_C, C interstitials and their associated defects) with different fluences, we were able to employ different techniques (*C-V*, DLTS, and EPR) to study the $Z_{1/2}$ and V_C defects in the same samples. It has been shown that $Z_{1/2}$ and V_C are the dominant defects responsible for the carrier compensation observed in the irradiated samples, suggesting that the $Z_{1/2}$ center originates from a C vacancy and is related to the EPR inactive $2-$ charge state of V_C.

Support by the Grant-in-Aid for Scientific Research (21226008 and 80225078) from the Japan Society for the Promotion of Science, the Swedish Energy Agency, the Swedish Research Council VR/Linné LiLI-NFM, and the Knut and Alice Wallenberg Foundation is gratefully acknowledged.

[1]T. Dalibor, G. Pensl, H. Matsunami, T. Kimoto, W. J. Choyke, A. Schöner, and N. Nordell, Phys. Status Solidi A **162**, 199 (1997).
[2]M. Weidner, T. Frank, G. Pensl, A. Kawasuso, H. Itoh, and R. Krause-Rehberg, Physica B **308–310**, 633 (2001).
[3]M. L. David, G. Alfieri, E. M. Monakhov, A. Hallén, C. Blanchard, B. G. Svensson, and J. F. Barbot, J. Appl. Phys. **95**, 4728 (2004).
[4]P. B. Klein, B. V. Shanabrook, S. W. Huh, A. Y. Polyakov, M. Skowronski, J. J. Sumakeris, and M. J. O'Loughlin, Appl. Phys. Lett. **88**, 052110 (2006).
[5]K. Danno, D. Nakamura, and T. Kimoto, Appl. Phys. Lett. **90**, 202109 (2007).
[6]L. Storasta, J. P. Bergman, E. Janzén, A. Henry, and J. Lu, J. Appl. Phys. **96**, 4909 (2004).
[7]K. Danno and T. Kimoto, J. Appl. Phys. **100**, 113728 (2006).
[8]H. Kaneko and T. Kimoto, Appl. Phys. Lett. **98**, 262106 (2011).
[9]T. Kimoto, S. Nakazawa, K. Hashimoto, and H. Matsunami, Appl. Phys. Lett. **79**, 2761 (2001).
[10]T. Umeda, Y. Ishitsuka, J. Isoya, N. T. Son, E. Janzén, N. Morishita, T. Ohshima, H. Itoh, and A. Gali, Phys. Rev. B **71**, 193202 (2005).
[11]N. T. Son, X. T. Trinh, L. S. Løvlie, B. G. Svensson, K. Kawahara, J. Suda, T. Kimoto, T. Umeda, J. Isoya, T. Makino, T. Ohshima, and E. Janzén, Phys. Rev. Lett. **109**, 187603 (2012).
[12]P. Carlsson, N. Son, F. Beyer, H. Pedersen, J. Isoya, N. Morishita, T. Ohshima, and E. Janzén, Phys. Status Solidi (RRL) **3**, 121 (2009).
[13]C. Hemmingsson, N. T. Son, O. Kordina, J. P. Bergman, E. Janzén, J. L. Lindström, S. Savage, and N. Nordell, J. Appl. Phys. **81**, 6155 (1997).
[14]C. G. Hemmingsson, N. T. Son, A. Ellison, J. Zhang, and E. Janzén, Phys. Rev. B **58**, R10119 (1998); **59**, 7768 (1999).
[15]T. Kimoto, T. Yamamoto, Z. Y. Chen, H. Yano, and H. Matsunami, J. Appl. Phys. **89**, 6105 (2001).
[16]S. Kagamihara, H. Matsuura, T. Hatakeyama, T. Watanabe, M. Kushibe, T. Shinohe, and K. Arai, J. Appl. Phys. **96**, 5601 (2004).
[17]S. Sasaki, K. Kawahara, G. Feng, G. Alfieri, and T. Kimoto, J. Appl. Phys. **109**, 013705 (2011).
[18]T. Hornos, A. Gali, and B. G. Svensson, Mater. Sci. Forum **679–680**, 261 (2011).

This article is copyrighted as indicated in the article. Reuse of AIP content is subject to the terms at: http://scitation.aip.org/termsconditions. Downloaded to IP: 130.54.110.72 On: Thu, 05 Jun 2014 04:13:16